

Press release

ZEISS, TRUMPF and Fraunhofer research team awarded the Deutscher Zukunftspreis 2020 for the development of EUV lithography

- **EUV lithography enables chips for state-of-the-art smartphones and automated driving**
- **World-leading manufacturing technology strengthens German-European position in global semiconductor business**

Oberkochen, Ditzingen, Jena, 25 November 2020

The German Federal President Frank-Walter Steinmeier announced the winners of the Deutscher Zukunftspreis 2020 (German Future Prize 2020) in a ceremony in Berlin today. The Federal President honored the team made up of Dr. Peter Kürz from the ZEISS Semiconductor Manufacturing Technology (SMT) segment, Dr. Michael Kösters from TRUMPF Lasersystems for Semiconductor Manufacturing, and Dr. Sergiy Yulin from the Fraunhofer Institute for Applied Optics and Precision Engineering (IOF) in Jena, bestowing on them his technology and innovation award for their project titled "EUV Lithography – New Light for the Digital Age".

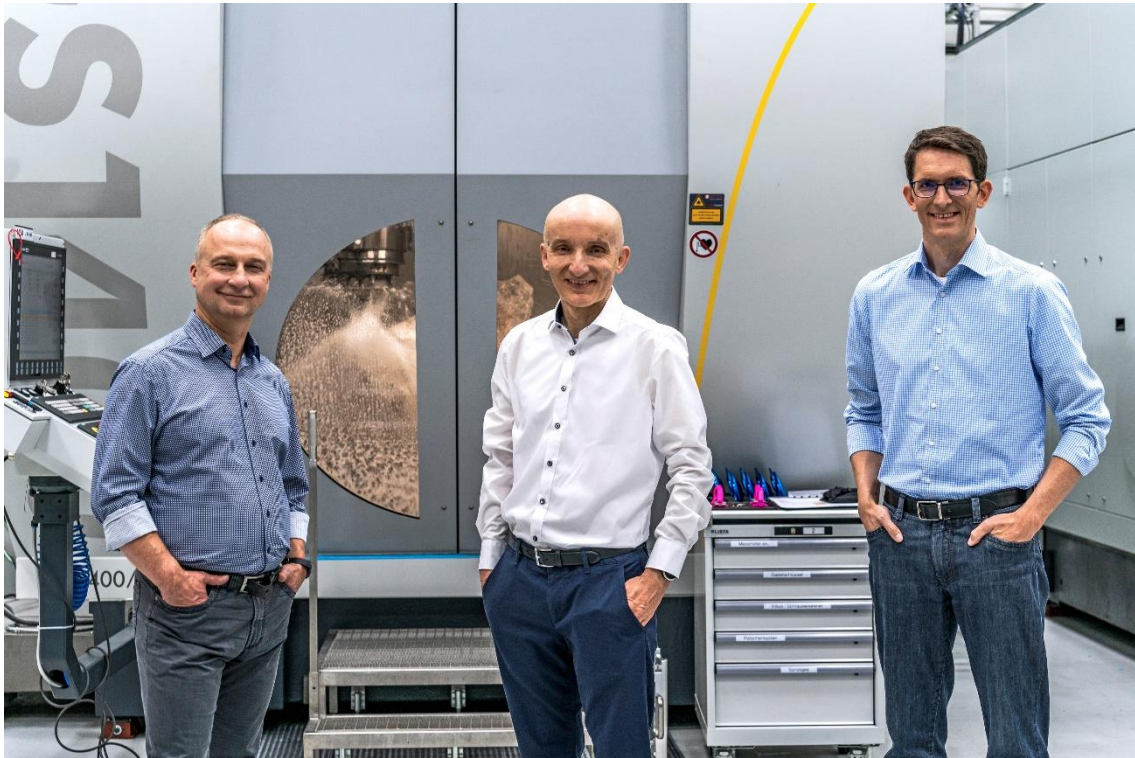
Successful market launch creates jobs

The winning team made a significant contribution to developing EUV technology and preparing it for industrial series production. The result? A future-proof technology backed by more than 2,000 patents which forms the basis for the digitalization of our daily lives and enables applications such as automated driving, 5G, Artificial Intelligence and other future innovations. Thanks to EUV, over 3,300 high-tech jobs have been created at ZEISS and TRUMPF to date and an annual turnover of more than one billion euros - with an upward trend - was generated in 2019.

Higher-performance and more energy-efficient and cost-effective microchips

The Dutch company ASML is the world's only EUV lithography machine manufacturer. As an integrator, the company designed the overall system architecture and the EUV source in particular. The high-power laser from TRUMPF for the EUV light source and the optical system from ZEISS are key components of these machines. EUV stands for "extreme ultraviolet" light, i.e. light with an extremely short wavelength. This unrivalled key technology can be used to produce significantly higher-performance and more energy-efficient and cost-effective microchips throughout in this decade and the next. Effective digitalization requires a continued and rapid increase in computing power. Today's smartphones are a million times more powerful than the computer used during the first Moon landing in 1969. This is made possible by a microchip that is smaller than a fingertip, but which has the capacity to accommodate more than fifteen billion transistors.

The manufacturing process for the latest chip generations is based on the use of EUV light, pushing the limits of what is technologically feasible. From the light source and the optical system in a vacuum through the surface coating of the mirrors used in the process - practically the entire exposure technology had to be developed from scratch.

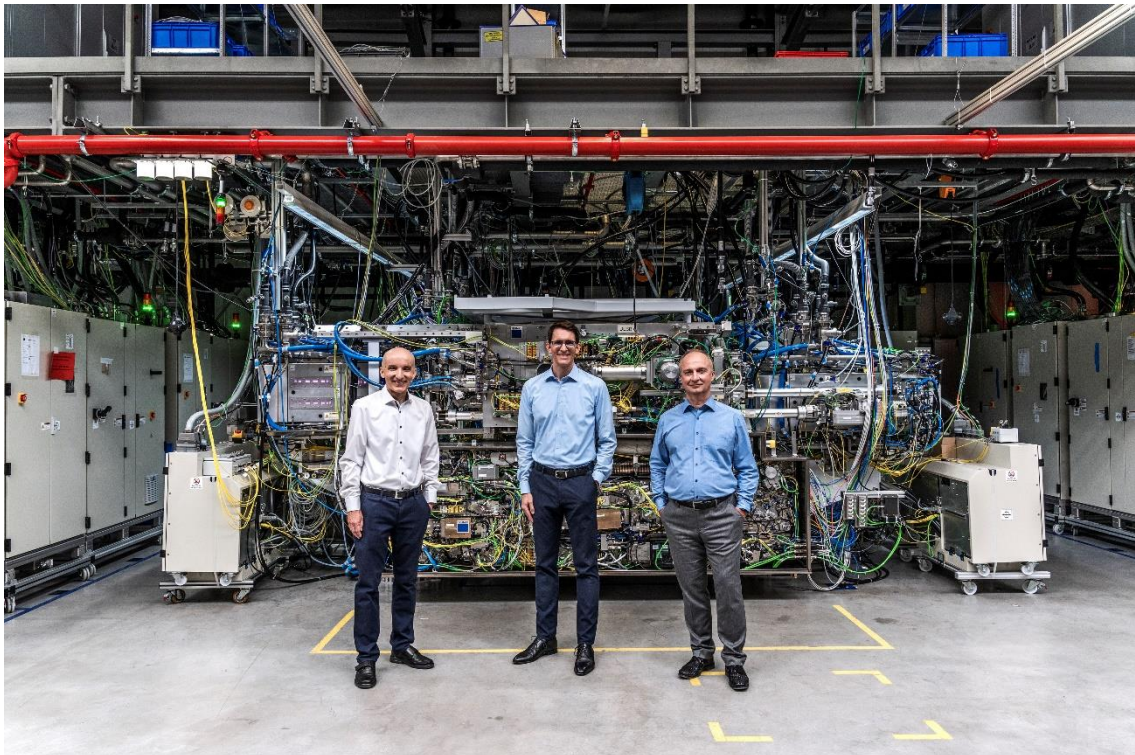


Awarded the Deutscher Zukunftspreis 2020 for their project "EUV Lithography – A New Light in the Digital Age" (from the left): Dr. Sergiy Yulin from the Fraunhofer Institute for Applied Optics and Precision Engineering (IOF); Dr. Peter Kürz, ZEISS SMT segment, and Dr. Michael Kösters from TRUMPF Lasersystems for Semiconductor Manufacturing; photo: © Deutscher Zukunftspreis / Ansgar Pudenz

EUV lithography - a German-European success story

"Heartfelt congratulations to our winning team, representing thousands of EUV developers. We and our partners are very pleased to receive this award from the German Federal President, which recognizes an enormously labor-intensive development effort and its translation into a technology that is dominating the global market," says Dr. Markus Weber, ZEISS Group Executive Board member and head of the Semiconductor Manufacturing Technology segment. "ZEISS stands for optical excellence and precision. This has always been a key factor in chip production. As a breakthrough innovation, EUV technology continues to enable major advances in digitization in business and society. We are proud to contribute to this together with our strategic partners ASML, TRUMPF and Fraunhofer".

TRUMPF Vice Chairman of the Group Management Board and Chief Technology Officer Peter Leibinger: "We are very pleased that Dr. Michael Kösters, Dr. Peter Kürz and Dr. Sergiy Yulin from TRUMPF, ZEISS and the Fraunhofer IOF have won the Deutscher Zukunftspreis 2020. By combining inventiveness, an understanding of technology, perseverance and good teamwork, they are a perfect example of how future technologies can be developed to industrial maturity through strong partnerships. The award shows us once again that a strong industry and an outstanding research landscape play a crucial role in meeting the challenges of this century. The mammoth EUV lithography project is also creating jobs during the Corona year while additionally ensuring that Europe plays a pioneering role in the production of state-of-the-art microchips".



The team of experts in front of the world's strongest pulsed industrial laser, which is used for light generation to enable EUV lithography (from left): Dr. Peter Kürz from the ZEISS SMT segment, Dr. Michael Kösters from TRUMPF Lasersystems for Semiconductor Manufacturing, and Dr. Sergiy Yulin from the Fraunhofer Institute for Applied Optics and Precision Engineering (IOF); photo: © Deutscher Zukunftspreis / Ansgar Pudenz

With the world's strongest pulsed industrial laser, TRUMPF supplies a key component for the exposure of the most modern microchips used in every modern smartphone. There is no economical alternative to this laser for generating the light required for EUV lithography.

The quality and form of the illumination system and the resolution power of the projection optics from ZEISS determine how small the structures on microchips can be. The mirrors used in the optical system therefore contain significant innovations. Since even the smallest irregularities lead to imaging errors, the world's "most precise" mirror was developed for EUV lithography. Fraunhofer was an important research partner in the sophisticated coating technology for the large-scale mirrors.

"We congratulate the researchers from ZEISS, TRUMPF and the Fraunhofer IOF on this great award for their excellent work. In EUV lithography, they have developed a technology that will provide a digitalization push globally and by so doing also lays the foundation for further innovations," says Prof. Reimund Neugebauer, President of the Fraunhofer-Gesellschaft. "Fraunhofer scientists played a major role in the development of the first EUV mirrors and beam sources in the almost three decades of research. The fact that EUV lithography is now being applied is also thanks to the intensive cooperation between science and industry as well as the spirit of research and the enduring commitment of all involved".

Honor for innovative achievements in engineering and the life sciences

The Deutsche Zukunftspreis has been presented every year since 1997. It is one of the highest accolades for scientific achievement in Germany and is worth 250,000 euros. It honors exceptional achievements in technology, engineering and the life sciences that have resulted in



viable products. Every year, during a multistage selection process, the prestigious jury selects three research teams and their innovation for the final round from among a large number of different projects, the "shortlist". Alongside their innovative achievements, the jury also evaluates the development's economic and social potential. Alongside the winning EUV team, a team from Carl Zeiss Meditec was also shortlisted. ZEISS was therefore the first company in the history of the Deutscher Zukunftspreis to hold two nominations. The award was presented in Berlin on 25 November 2020 under pandemic restrictions at Verti Music Hall by Federal President Frank-Walter Steinmeier. ZEISS and TRUMPF are donating the prize money for charitable purposes.

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About ZEISS

ZEISS is an internationally leading technology enterprise operating in the fields of optics and optoelectronics. In the previous fiscal year, the ZEISS Group generated annual revenue totaling more than 6.4 billion euros in its four segments Semiconductor Manufacturing Technology, Industrial Quality & Research, Medical Technology and Consumer Markets (status: 30 September 2019).

For its customers, ZEISS develops, produces and distributes highly innovative solutions for industrial metrology and quality assurance, microscopy solutions for the life sciences and materials research, and medical technology solutions for diagnostics and treatment in ophthalmology and microsurgery. The name ZEISS is also synonymous with the world's leading lithography optics, which are used by the chip industry to manufacture semiconductor components. There is global demand for trendsetting ZEISS brand products such as eyeglass lenses, camera lenses and binoculars.

With a portfolio aligned with future growth areas like digitalization, healthcare and Smart Production and a strong brand, ZEISS is shaping the future of technology and constantly advancing the world of optics and related fields with its solutions. The company's significant, sustainable investments in research and development lay the foundation for the success and continued expansion of ZEISS' technology and market leadership.

With over 31,000 employees, ZEISS is active globally in almost 50 countries with around 60 sales and service companies, 30 production sites and 25 development sites. Founded in 1846 in Jena, the company is headquartered in Oberkochen, Germany. The Carl Zeiss Foundation, one of the largest foundations in Germany committed to the promotion of science, is the sole owner of the holding company, Carl Zeiss AG.

Further information at www.zeiss.com

About TRUMPF

TRUMPF is a high-tech company offering manufacturing solutions in the fields of machine tools and laser technology. The Company drives digital connectivity in manufacturing through consulting, platform products and software. TRUMPF is a technology and market leader in highly versatile machine tools for sheet metal processing and in the field of industrial lasers.

In 2019/20, the company employed some 14,300 people and generated sales of about 3.5 billion euros (preliminary figures). With over 70 subsidiaries, the TRUMPF Group is represented in nearly every European country as well as in North America, South America and Asia. The company has production facilities in Austria, China, the Czech Republic, France, Germany, Italy, Japan, Mexico, Poland, Switzerland, the United Kingdom and the United States.

Find out more about TRUMPF at www.trumpf.com



About Fraunhofer

The Fraunhofer-Gesellschaft, headquartered in Germany, is the world's leading applied research organization. With its focus on developing key technologies that are vital for the future and enabling the commercial exploitation of this work by business and industry, Fraunhofer plays a central role in the innovation process. As a pioneer and catalyst for groundbreaking developments and scientific excellence, Fraunhofer helps shape society now and in the future. Founded in 1949, the Fraunhofer-Gesellschaft currently operates 74 institutes and research institutions throughout Germany. The majority of the organization's 28,000 employees are qualified scientists and engineers, who work with an annual research budget of 2.8 billion euros. Of this sum, 2.3 billion euros is generated through contract research.

Find out more about Fraunhofer at <https://www.fraunhofer.de/en>